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(54) Title: ETCHING SOLUTION, CONTAINING HYDROFLUORIC ACID

(54) Bezeichnung: ÄTZLÖSUNG, FLUSSSÄURE ENTHALTEND

(57) Abstract: The invention relates to etching solutions, containing hydrofluoric acid and organic solvents, for use in the production of integrated circuits. The inventive etching solutions are particularly suitable for selectively etching layers of doped silicate.

(57) Zusammenfassung: Diese Erfindung betrifft Ätzlösungen zur Verwendung im Herstellungsprozess von integrierten Schaltungen, die Flusssäure und organische Lösungsmittel enthalten. Besonders sind die erfindungsgemässen Ätzlösungen zur selektiven Ätzung sowohl von dotierten Silikatschichten geeignet.

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